

Crystal Growth Problems Solved by Hans J. Scheel

- 1958 Chromatographic separation, purification and crystallization of **Brazilian Curare alkaloids** (for structure determination, product development of Hoffmann La Roche; with Prof. Paul Karrer at Chemical Institute of University of Zurich).
- 1959 **γ – Quinacridone & other organic pigment dyes:**
These dyes are stable to about 400°C, not soluble in any solvent, not melting; problem for chemical pigment industry that no crystals could be grown for determination of the structure.
Solution: Long-time sublimation (90 to 200 days) in optimised temperature gradient.
(with H. Koyama, K. Ogawa and F. Laves).
Naturwiss. **53**(1966)700; 701; Z. Krist. **130**(1969)405-419.
(1989 HJS was welcomed by Hoechst/Frankfurt as "Mr. Quinacridone").
- 1960 – 1964 **Secret of Corning-Ware (Pyroceram/Vitroceram-Type Glass):**
Simulation with a low-melting model system showed relation of phase separation to nucleation and crystallisation of pyroceram-type glasses, explained Pyroceram Mechanism.(with G. Bayer, O.W. Flörke, W. Hoffmann).
Glastechn. Berichte **39**(1966)242-261.
- 1964 – 1971 Setting up crystal growth laboratories at ETH Zurich & IBM Zurich Research Laboratory; design of versatile Verneuil furnace for flame-fusion growth.
- 1968 Size of ferromagnetic NaCrS₂ crystals increased 500 times by **new Na₂S_x-solvent** which then allowed growth of ZnS, CdS, FeS₂, CoS₂, NaInS₂, etc.
J. Crystal Growth **24/25**(1974)669-673; patents.
- 1970 – 1972 Size of GdAlO₃ crystals increased 145x by novel stirring technique in sealed crucibles, the **Accelerated Crucible Rotation Technique ACRT**. This allows to control nucleation, to achieve high stable growth rates (inclusion-free growth), and to solve the striation problem. Forced convection instead of popular reduced convection.
(First Award of Swiss Crystal Growth Association 1972,
Outstanding Contribution Award & Invention Award from IBM;
now ACRT is widely applied in research and in industrial production for YIG, CdTe & III-V solid solutions, Si, LiNbO₃). J. Crystal Growth **13/14**(1972)560-565: Selected as a classical paper of crystal growth in the 20th century.
Theoretical analysis of ACRT by E.O. Schulz-DuBois: J. Crystal Growth **12**(1972)81.
- 1972 The **maximum stable growth rate** for growth of large inclusion-free crystals from high-temperature solutions derived (with D. Elwell). J. Crystal Growth **12**(1972)153.
- 1972 – 1976 Invented and developed a **slider-free liquid phase epitaxy method (MultiLPE)** for multilayers and superlattices and achieved the **transition** from misoriented macrostep-surface to a **facet** which was proven by scanning
1980 tunnelling microscopy and by Nomarski differential-interference-contrast
1982 micrographs to be **atomically flat** and
1995 also theoretically explained.
J. Crystal Growth **42**(1977)301-308; Appl. Phys. Lett. **37**(1980)70-73;
J. Crystal Growth **60**(1982)199-202 (with G. Binnig and H. Rohrer);
J. Crystal Growth **149**(1995)187-195 (with A. Chernov). **Patents.**
- 1976 – 1979 Designed a **Super- Glovebox** with less than 0.03 ppm O₂ and humidity (with P. Dill).
Invited lecture at AACG Workshop on "Purification of Materials for Crystal Growth and Glass Processing", Pajaro Dunes/Watsonville, California May 14-17, 1985.
- 1976 Flame-fusion (Verneuil) growth of SrTiO₃ (with J.G. Bednorz, his master thesis).
J. Crystal Growth **41**(1977)5-12; Ferroelectrics **13**(1976)507-509.
- 1977 Growth of dislocation-free SrTiO₃ from high-temperature solutions (with P. Dill).
Invited at EMF-3 in Zurich Sept. 22-26, 1975;
Ferroelectrics **13**(1976) Nos. 1-4, 507-509.

- 1982 – 1983 & 2001 The **“inherent” crystal growth problem of striations** theoretically and experimentally solved by **forced convection** (with D. Rytz, J. Sommerauer, R.H. Swendsen).
J. Crystal Growth **59**(1982)468-484; **62**(1983)291-298; **233**(2001) 609-617.
- 1982 & 2001 **Distribution coefficient $k = 1$ achieved in crystal growth from high-temperature solutions** (with R.H. Swendsen). J. Crystal Growth **233** (2001) 609 - 617.
- 1985 – 1986 **Discovery of Taylor vortices in Czochralski melts from analysis of special dimension-less numbers** (with J. Sielawa). Proceedings of the International Sympos. High-Purity Materials (Dresden May 6-10, 1985) 232 - 244.
- 1987 & 1988 & 1989 **First “free” crystal of $\text{YBa}_2\text{Cu}_3\text{O}_{7-x}$ and thick YBCO crystals grown.** (with F. Licci, W. Sadowski). Invited at First Internatl. Conference on High-Temperature Superconductors and Materials & Mechanisms of Superconductivity Interlaken Feb.28-March 4, 1988 in Physica C **153-155**(1988) 44 - 49, 431 - 432; J. Less-Common Metals **150**(1989)219-217; **151**(1989)199-211; Mat.Res.Bull. **19**(1994)26-32.
- 1989 **Leading-Edge Growth (LEG) mechanism** discovered which explains the growth of the majority of thin platelets (with Ph. Niedermann).
J. Crystal Growth **94**(1989)281-284.
- 1992 & 1993 **Liquid Phase Epitaxy of YBCO and “atomically flat” surfaces** (with F.-K. Reinhart, H.P. Lang, C. Klemenz, H.-J. Günterodt) at ICCG-10 San Diego Aug. 16-21, 1992 and J. Crystal Growth **129**(1993)421-428; Appl. Phys. Lett. **65**(1994)901-903; Physica C **265**(1996)126-134.
- 1996 **Growth of colourless high - quality anatase (TiO_2) crystals by chemical vapour transport** (with L. Kavan, M. Graetzel, S.E. Gilbert, C. Klemenz).
J. Amer. Chem. Soc. **118**(1996)6716-6723.
- 1996 & 2000 **Liquid Phase Epitaxy of Gallium Nitride GaN** (with C. Klemenz).
Electrochem. Soc. Proc. Vol. **96-11** (1996)20-36; at ACCG-11 (1999) and J. Crystal Growth **211**(2000)62-67.
H.J. Scheel and D. Elwell “Liquid Phase Epitaxy of Gallium Nitride”, Chapter 7 in “Liquid Phase Epitaxy of Electronic, Optical and Optoelectronic Materials”, editors P. Capper and M. Mauk, Wiley & Sons 2007, p. 203 - 225.
- 1997 **Control of Epitaxial Growth Modes for High-Performance Devices**
Definition and interrelation of 8 epitaxial growth modes and their occurrence as function of supersaturation and misfit. Proceedings First Internatl. Symp. on Lasers and Nonlinear Optical Materials (Singapore Nov. 3 - 5, 1997), editor T. Sasaki, Data Storage Institute Singapore 1997, 10-18;
H.J. Scheel “Control of Epitaxial Growth Modes for High-Performance Devices”, Chapter 28 in “Crystal Growth Technology”, editors H.J. Scheel and T. Fukuda, Wiley, Chichester UK 2003, paperback 2004, 623-644;
H.J. Scheel “Introduction to Liquid Phase Epitaxy”, Chapter 1 in “Liquid Phase Epitaxy of Electronic, Optical and Optoelectronic Devices”, editors P. Capper and M. Mauk, Wiley, Chichester UK 2007, 1-19.
- 1975 **Book “Crystal Growth from High - Temperature Solutions”** by D. Elwell and H.J. Scheel, Academic Press, London-New York 1975, “reprint” (with Chapter 11 on „Crystal Growth and Liquid Phase Epitaxy of High-Tc Superconductors“, Appendix A. „Growth of Striation-free Crystals“, Appendix B. „Epitaxy and the Importance of LPE“ on the website of HJS).
- 1972, 1976, 1988 & 1995 **Patents on Growth of CdS, on MultiLPE, and on Co-Rotating Ring Czochralski Method (CRCZ) for growth of homogeneous crystals from melts and for a nearly convection-free zone (in front of growing crystal) surrounded by a mixed melt.**